From Eye to Insight

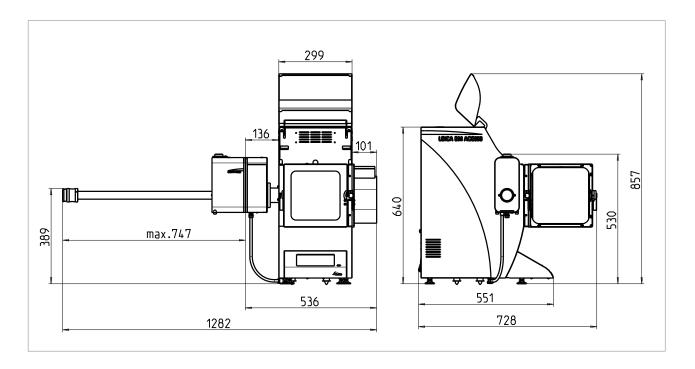


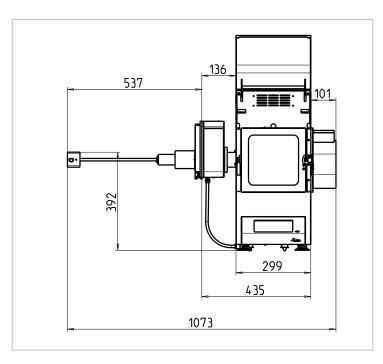


EM ACE600 Technical Data Sheet

EM ACE600

High Vacuum Coater







OPERATIONAL AND GENERAL DATA

specimen tables (diameter)	Ø 104 mm, flat with 25 holes for standard (12,7 mm/ 1/2") SEM stubs opt. Ø 104 mm planetary for 6 x 4 SEM stubs Ø 60 mm, low angle rotary shadowing and grid stage, especially for high angled e-beam coating
angled sources	25°
stage tilt	auto stage: 0 to ± 60°
QSG Film Thickness Monitoring Resolution	one decimal (0.1 nm accuracy) new quartz crystal: 6 MHz
user interface	integrated touch panel, up to 100 protocols, material files and sequences can be stored
USB port	usable for ≤ 32 GB USB 2.0 memory sticks
VCT100 adaptor plate	pressured air 5.8 - 6.2 bar

OPERATING GAS CONNECTION

venting gas	N ₂ , 0.2 - 0.5 bar, 99.99% purity (optional)
connection for N ₂ gas	Ø 6 mm push-fit connector for polyamide hose

ELECTRICAL DATA

supply/connecting voltage	100 / 115 / 230 Vac
frequency	50 / 60 Hz
power consumption while pumping	100 W
idle power consumption	~ 25 W (turbo-pump in stand-by)
power consumption during coating	Sputter, Carbon Thread: 200 W, E-Beam, Carbon Rod: 1000 W

VACUUM SYSTEM

ultimate vacuum	≤ 2x10 ⁻⁶ mbar**
ultimate vacuum with Meissner Trap	≤ 7x10 ⁻⁷ mbar**
pumping time to 5E-5 mbar	approx. 15 min.*
pumping	oil-free, 4-stage diaphragm pump (13 l/min) and (67 l/s) turbo-molecular drag pump
maintained vacuum with inactive pumps	~ 1 mbar

^{*} after 8 min (= pumps on full speed) a clean instrument reaches a vacuum better than 1E⁴ mbar (this is suitable for running a process)

^{**}Reached within 24 hours pumping once the instrument has reached 2x10⁻⁶ mbar after installation and is kept clean

DIMENSIONS AND WEIGHT	WIDTH	DEPTH	HEIGHT	NET WEIGHT
basic unit	~ 300 mm	~ 540 mm	~ 640 mm	~ 65 kg
basic unit e-beam	~ 300 mm	~ 660 mm	~ 640 mm	~ 70 kg
vacuum chamber	200 mm	150 mm	195 mm	
instrument packed (one box)	600 mm	800 mm	920 mm	~ 74 kg
with dewar	~ 400 mm	~ 540 mm	~ 640 mm	
with dewar & VCT500 dock	~ 540 mm	~ 540 mm	~ 640 mm	
with VCT500 Shuttle	~ 1290 mm	~ 540 mm	~ 640 mm	
with load lock	~ 1080 mm	~ 540 mm	~ 640 mm	

SPUTTER

materials	Aluminium, Chrome, Cobalt, Copper, Gold, Gold/Palladium, Iridium, Molybdenum, Nickel, Platinum, Platinum/Palladium, Silver, Tungsten, Titanium
sputter target	thickness max. 1 mm, Ø 54 mm
working distance	30 - 100 mm
coating time	1 - 1800 s
coating thickness	0.1 - 1000 nm
sputter current	15 - 150 mA
sputter vacuum	8E-3 to 1E-1 mbar
base vacuum	1E-6 to 1E-2 mbar
purge cycles	0 - 50
pre-sputter	ON/OFF
pre-sputter current	10 - 150 mA
pre-sputter time	1 - 300 s
process gas	Argon (99.999% purity) at 0.5 bar (two-stage reduction valve recommended)
connection for Argon gas	Ø 6 mm push-fit connector for polyamide hose
gas consumption	18 SCCM

GLOW DISCHARGE

discharge current	5 - 15 mA
discharge time	1 - 1800 s
working distance	10 - 100 mm
process vacuum	1E-1 to 5E-1
base vacuum	1E-6 to 1E-2

CARBON THREAD

material	Leica Carbon Thread (~ 0.25 g/m), 4 sections
methods	pulse / flash
double thread	YES / NO
coating thickness	0 - 100 nm
number of pulses	20 - 100
number of flashes	1 - 4
coating rate	approx. 0.3 nm/s (pulsing)
base vacuum	1E-6 to 1E-2 mbar
heat current	1 - 40 A
heat voltage	3 - 18 V
heat time	0 - 120 s
pulse power	0 - 720 W
pulse wait time	5000 - 15800 ms
pulse on time	10 - 2000 ms
flash current	1 - 40 A
flash voltage	3 - 18 V

ENVIRONMENTAL CONDITIONS

usage	indoor use, altitude up to 2000 m
temperature range	+15 to +30 °C
humidity	max. 80% RH (no condensation)
pollution degree (IEC 61010-1)	2
operating environment	Air or Nitrogen only

CLEANING

All surfaces can be cleaned with a damp cloth moistened with either aqueous cleaning agents or 50% ethanol. Do NOT use ACETONE! To clean the vacuum chamber the Leica cleaning product is recommended.

E-BEAM

materials	Carbon and Platinum/Carbon
high voltage	max. 1.15 kV
emission current	max. 400 mA
coating time	1 - 1800 s
coating thickness	0.1 - 100 nm
coating angle	auto stage: 1 $^{\circ}$ to > 90 $^{\circ}$ cryo stage: 34 $^{\circ}$ to > 90 $^{\circ}$
distance to specimen	auto stage: 164 - 191 mm cryo stage: 164 - 175 nm
carbon feed	10 mm Ø 3 mm rod, density 2.45 g/cm ³
platinum / carbon feed	10 mm Ø 2 mm rod with recess for PT insert, density 19.45 g/cm ³
cathodes	Tungsten (W) Cathodes
maximum coating rate	Carbon 0.3 nm/s, Platinum/Carbon 0.06 nm/s
QSG Film Thickness monitoring resolution	0.1 nm
target power	30 - 300 W
degas	ON / OFF
degas power	50 - 150 W
degas time	30 - 300 s
base vacuum	1E-6 to 1E-4 mbar

CARBON ROD

materials	Carbon
high voltage	max. 1.15 kV
emission current	max. 400 mA
coating time	1 - 1800 s
coating thickness	0.1 - 100 nm
working distance	30 - 100 nm
carbon feed	25 mm Ø 3 mm rod, density 2.45 g/cm ³
maximum coating rate	approx. 0.3 nm/s
tilt angle	auto stage: ± 60°
voltage	1.2 - 7.2 V
base vacuum	1E-6 to 1E-2 mbar
pre-heat	ON / OFF
pre-heat voltage	1.2 - 4.5 V
pre-heat time	30 - 3600 s

CRYO STAGE / FREEZE FRACTURE & ETCHING

minimum temperature (dewar)	-190 °C
temperature control stage	-170 °C to -80 °C heat up to +60 °C for 1 hour
knife temperature	-160 °C
time for cooling from 20 °C to -180 °C	approx. 45 min
freeze etching rate (app. guideline)	at 2 x 10 ⁻⁶ mbar at -100 °C about 2 nm/s
freeze etching hold time	max. 4 hours
stage tilt	cryo stage: ± 27°
knife feed	1-100 μm / s
cutting distance	0 - 6000 μm
dewar size	0.75
Hazard notes	normal operational state specification of gaseous nitrogen peak emission (this occurs mainly during cool down from room temperature to cryo) 4 m³/h Please see saftey introduction of the operating manual

TRANSFER: VCT500 / LOAD LOCK

transfer feed through	Ø 50 mm
transfer stages	cryo stage or motorized stage with table to receive 4 VCT holder
VCT500 base vacuum	< 1E-4 mbar
VCT500 pump time	20 - 120 s
VCT500 purge time	5 - 30 s
VCT500 purge cycles	0 - 30
VCT500 time out attach	20 - 300 s
VCT500 shuttle waiting time	5 - 30 s
VCT500 pressure threshold	5E0 to 5E+1
load lock pump time	20 - 120 s
load lock purge time	5 - 30 s







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